

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Application of:

Han-Ming Wu et al.

Serial No: 10/759,641

Filed: January 16, 2004

For: Purging Gas from a
Photolithography Enclosure
Between a Mask Protective
Device and a Pattern Mask

Examiner: Nguyen, Hung

Art Unit: 2851

PRELIMINARY AMENDMENTCommissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Prior to examination of the present RCE application, the Applicants respectfully request that the Examiner enter the following amendments and consider the following remarks.

CERTIFICATE OF FACSIMILE

I hereby certify that this correspondence is being transmitted via facsimile on the date shown below to the United States Patent and Trademark Office.

March 6, 2006

Date of Deposit

Pat Sullivan

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Signature

Pat Sullivan

March 6, 2006

Date